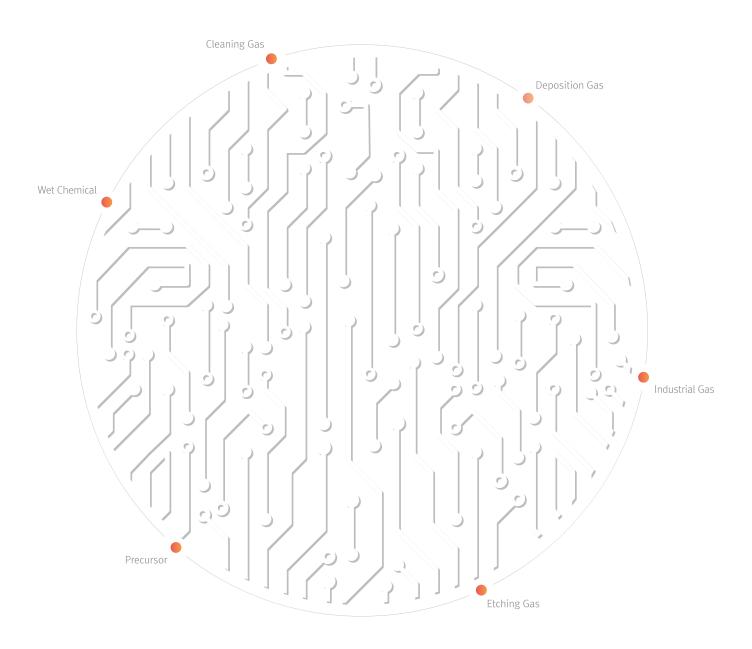
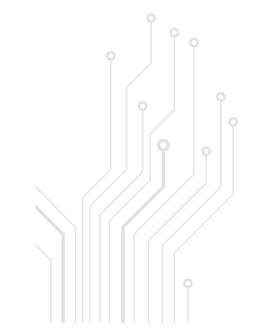
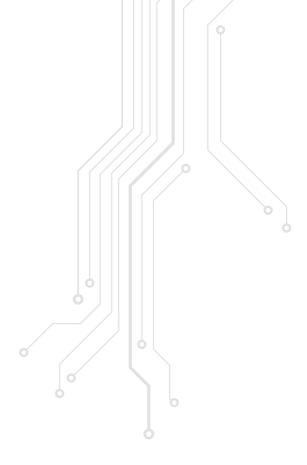
GAS & IT MATERIALS TOTAL SOLUTION PROVIDER





Global No.1 Total Solution Provider





GAS & IT MATERIALS TOTAL SOLUTION PROVIDER



01. OVERVIEW

SK materials

With a core focus on semiconductor materials, SK materials incessantly strives to become the leading total solutions provider for gas & IT materials, with its diverse portfolio of products and services aimed to create value for its customers.

SK materials moves forward as a Total Solution Provider in the Gas & IT Materials industry.



Thanks to the ceaseless R&D efforts since its founding in 1982, SK materials was the first ever in Korea to localize Nitrogen trifluoride (NF₃) special gas in 2001.

NF₃ is a special cleaning gas that removes residues in chambers used during semiconductor manufacturing processes. SK **materials** is the unrivaled global leader in the production and sales of such gas, taking up a lion's share of over 40% of its global market share.

Our competitive edge in the special gas sector is once again showcased by our production levels of tungsten hexafluoride (WF6) and monosilane (SiH4), ranking world top one and two respectively, as well as our production and sales of dichlorosilane (SiH2Cl2) and disilane (Si2H6).

SK materials has its headquarters and plants in Yeongju, Gyeongsangbuk-do, and has established legal entities overseas in Taiwan and Japan in 2010, Jinjiang, China in 2011, Xian, China in 2013, and Shanghai, China in 2019. The Jinjiang entity, boasting a production capacity of 1,500 tons of nitrogen trifluoride, serves as an outpost for occupying the evergrowing Chinese market. Sales entities in Taiwan, Japan, Xian and Shanghai are supporting the company expand its influence in the global market.

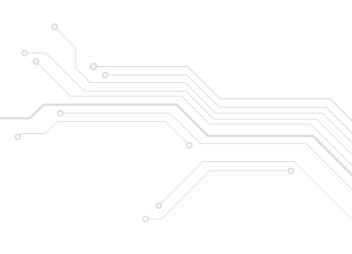
With the 2016 acquisition of SK airgas, which produces and supplies industrial gases such as oxygen and nitrogen, SK materials has been growing its share in the industrial gas market via proactively responding to customer needs. We also acquired an industrial carbon dioxide (CO₂) manufacturer Hanyu

Furthermore, **SK trichem**, which jointly manufactures precursors with global semiconductor materials producers, and SK showa **denko**, an etching gas producer, were founded to diversify our product portfolio. This also helped expand our business scope to the materials sector, which now witnesses ever-growing demand with the proliferation of semiconductor circuit scaling and 3D NAND flashes.

As a result, SK materials has shown sound fiscal performance, rewriting its record in annual sales at KRW 687.3 billion (consolidated) in 2018. Since its incorporation into the SK Group in 2016, **SK materials** has been maximizing values for all stakeholders including customers and shareholders, via providing unparalleled customer service, all the while creating synergies.

The global semiconductor and display market is changing at an unprecedented pace, as IT technologies like AI, IoT, and big data further advance and new players in emerging economies like China surface. Against this backdrop, SK materials will revamp both its cost and quality competitiveness through ceaseless innovation in its manufacturing processes, while also actively investing in R&D of new, next-generation products.

As such, we will put forth our best efforts to secure our position as the unmatched global leader by providing tailored solutions that meet market needs even under a changing paradigm.



Chemical in 2019, with an aim of securing new semiconductor materials and sharpening our competitiveness for future operations.

SK materials growing as a global top tier.

1982~ 2000

Frontier of the specialty gas in Korea

1982 Establishment

- 1998 Established Central Technology Research Center annexed to the company
- 1999 Listed in KOSDAQ

02. HISTORY

2001 ~

2010

At a time when semiconductors were considered as an unfamiliar business area and when specialty gases used in semiconductor fabrication processes were imported, SK materials became the first Korean company which produces nitrogen trifluoride(NF₃), using our own product development capabilities.

With continuous challenges and innovation, SK materials aims to grow the company's business beyond the specialty gas market where it is the world's largest producer of nitrogen trifluoride(NF₃) and tungsten hexafluoride(WF₆), and also the second largest manufacturer of silane(SiH₄). Since SK materials expands into other industrial gases, precursors, etching gas, services, and logistics solutions, it creates even more values.

natio	aring a foundation as a onal industry through		Leaping in Gas 8	
2001	Completed 1st NF3 Plant	2011	Cor Esta	
2004	Completed 1st WF6 Plant Completed 2nd NF3 Plant	2012	Cor Cor	
2005	Completed 1st SiH4 Plant	2013	Est	
2007	Completed 3rd NF ₃ Plant	2016	Bec	
2008	Completed 1st SiH2Cl2 Plant		Acq Esta	
2010	Completed 2nd SiH4 Plant Established SK materials Japan Co., Ltd.		Con Con	
	and SK materials Taiwan Co., Ltd.	2017	Suz Esta Cor Cor	
		2018	Ado Ent (HS	
		2019	Fst	

2011~

g to be a global leader & IT materials

mpleted 4th NF₃ Plant tablished SK materials Jiangsu Co., Ltd. in China

ompleted NF3 China Plant (SK materials Jiangsu Co., Ltd.) ompleted Si₂H₆ Plant

tablished SK materials Xian Co., Ltd. in China

ecame an affiliate of SK Group cquired SK airgas (SK airgas Incorporated) tablished SK trichem Co., Ltd. ompleted 2th WF6 Plant ompleted 5th NF3 Plant

uzhou sales office open stablished SK showa denko Co., Ltd. ompleted 3th WF₆ Plant ompleted 6th NF3 Plant

dditional acquisition of SK airgas shares (100% subsidiary) nter High Performance Wet Chemical Products business HSP cooperation development)

2019 Established SK materials Shanghai Co., Ltd. in China Acquired Hanyu Chemical

03. CORPORATE CULTURE

SKMS SK Management System

The SK Management System(SKMS), established in 1979, defines SK's governing philosophy and methodology, which are embodied in its management approach. SKMS has provided a foundation for SK's corporate culture through the consensus of all SK People. SK's sustained growth and consistent development to date can be largely attributed to its SKMS-based management activities and the establishment of its corporate culture.

All SK People voluntarily and willingly practice the SKMS. As a result, they contribute to corporate growth and development while achieving their own happiness at the same time.

SUPEX Quest

Pae-gi

In order to be a happier company, SK aims for the SUPEX, or Super Excellent Levels. This is the highest goal that any person can reach, and we continuously strive to achieve these levels.

Voluntary and Willing Brain Engagement (VWBE)

SK is fully aware that its employees are the focus of the management and the pursuit of SUPEX can only be realized when employees give their best. We believe that this will be attained by our employees engaging in the "Voluntarily & Willingly Brain Engagement (VWBE)" strategy.

Happiness of Stakeholders

their capabilities to the maximum.

SK believes that its mission is to create greater happiness for its numerous stakeholders. The ultimate goal that we pursue is being happy by making those around us happy.

"Pae-gi" refers to a state where the brain is voluntarily and

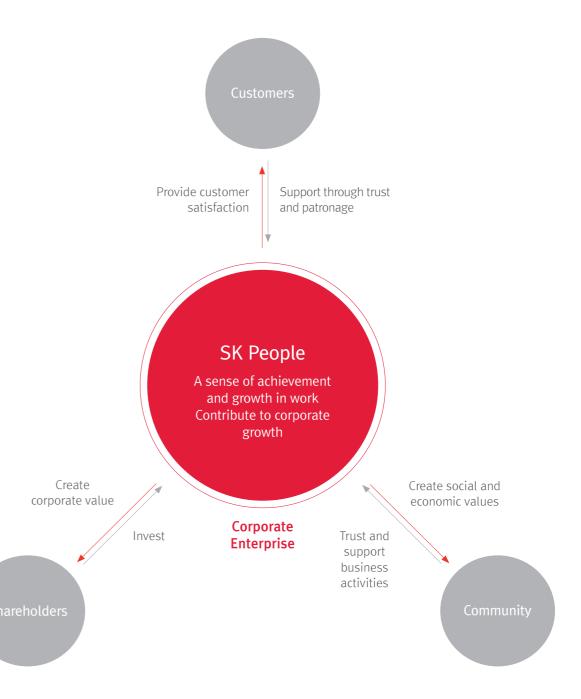
willingly engaged. People with "Pae-gi" take on and achieve

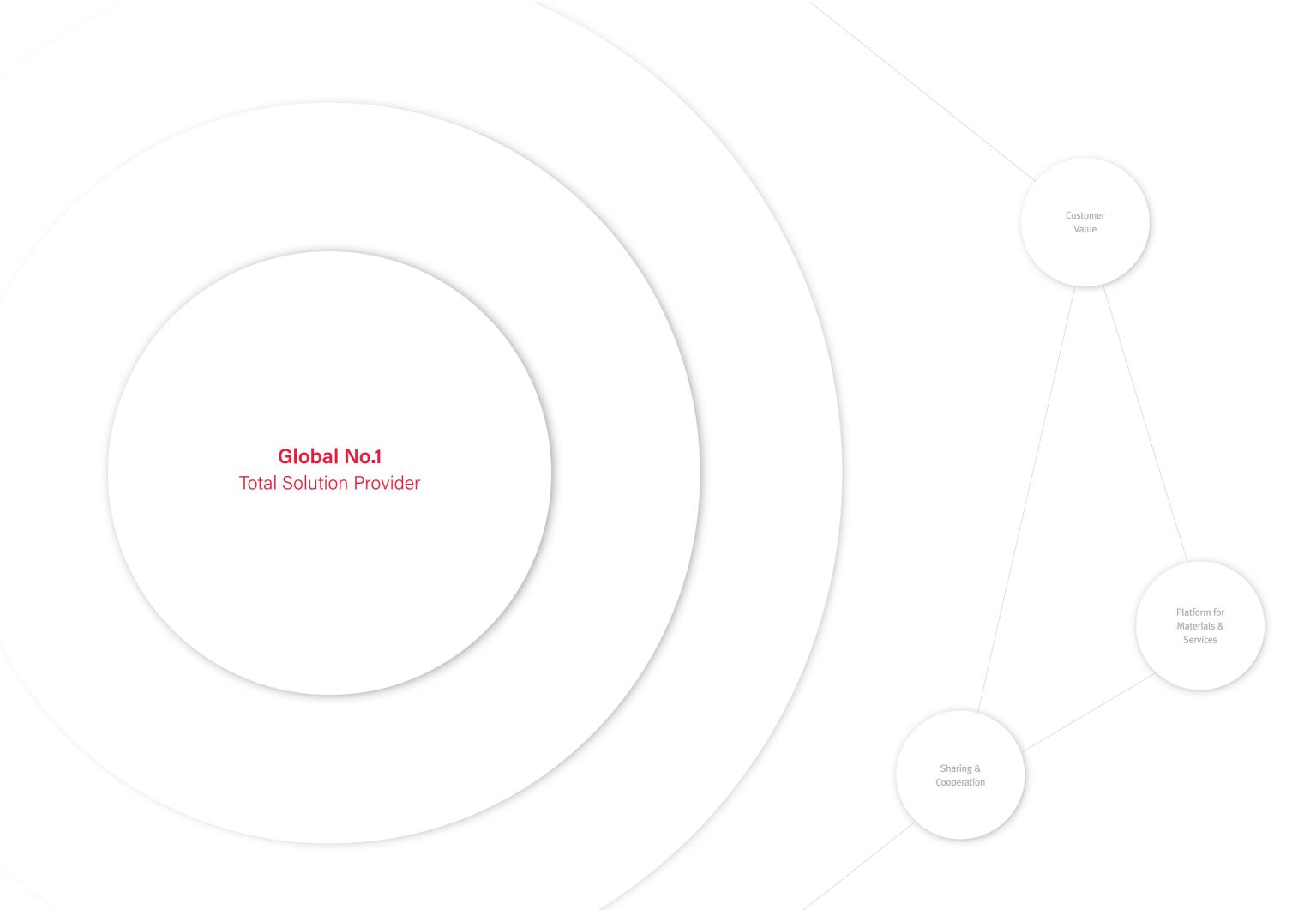
higher goals, strive to develop required capabilities, and

produce better performance through teamwork. SK attaches

great importance to encouraging "Pae-gi," while creating

the best possible environment so that they can demonstrate



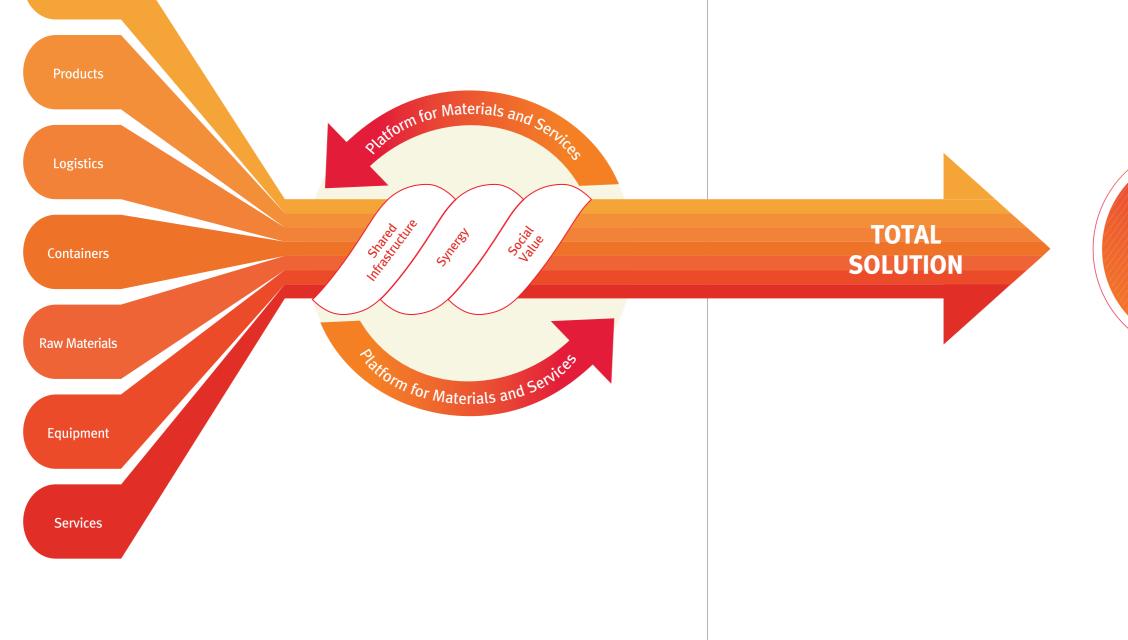


04. VISION

The formation of such an materials platform will deliver goods and services demanded by SK materials' customers so that SK materials can succeed in not only becoming the leading Total Solution Provider on a global scale but also in creating a business model capable of sustainable growth.

Global No.1 Total Solution Provider

In order to offer greater value to its customers, SK materials is sharing tangible / intangible assets and pursuing collaborative work with its core players in various fields such as raw materials, logistics, chemical containers, and services. This is a part of SK materials' committed effort to build a platform for materials and services so that customer value will increase.





Business Information

A variety of materials produced by SK materials are used in the most cutting–edge manufacturing processes of semiconductor displays, which shall shape the new tomorrow.

SK materials will continue to secure its position as the best partner creating customer value, with its continuous development of new products and provision of unmatched services.



1. Cleaning Gas

As the first manufacturer of nitrogen trifluoride(NF₃) in Korea, SK materials has been stably providing its customers with high–quality nitrogen trifluoride through novel technology development and proactive investments in facilities since 2001.

Nitrogen trifluoride(NF3)

 NF_3 is used during the manufacturing process of semiconductor, display, and PV, as it removes residues from inner wall of the chamber after CVD manufacturing process.

\mathcal{O}° Carbon dioxide(CO₂)

CO₂ is a supercritical fluid with zero surface tension, and is used as a gas to remove the impurities from semiconductor wafers following the completion of the etching process. It is also used for ArF immersion or EUV equipments. It offers both the advantages of a liquid that easily dissolves impurities, and gas that removes residues settled deep inside the equipment by accurately reaching the corners of even the finest patterns.

2. Deposition Gas

SK materials manufactures and sells various deposition gases for deposition of film in semiconductors, display panels, and solar cells. SK materials continuously develops new deposition gases to keep pace with the rapid changes in the IT industry.

Tungsten hexafluoride(WF6)

WF₆ is used in patterning semiconductor to form metal contacts and gates.

Monosilane(SiH₄)

SiH₄ is used during the manufacturing process of semiconductor, display and PV, where it is employed for Si insulator film and Si anti–reflection layer deposition.

, Monochlorosilane(SiH₃Cl)

SiH₃Cl is a precursor material used in the manufacturing of semiconductors and display panels.

တို္င္စ္တ္တဲ့ Disilane(Si₂H₆)

 $\rm Si_2H_6$ is used during the manufacturing process of semiconductor, display and PV, where it is employed for Si insulator film and Si anti–reflection layer deposition.

Dichlorosilane(SiH₂Cl₂)

 SiH_2Cl_2 is a gas used for nitride(SixNy) deposition.

3. Industrial Gas

Industrial gases are being used in various industries, such as petrochemicals, semiconductors, steel, healthcare, and food. SK materials highly purifies its industrial gases by using air-separation units and stably delivers them by means of on-site supply, pipelines, and tank lorries.

Oxygen(O₂)

Oxygen is used in various industries including iron and steel, automobiles, machinery, and chemicals. Its oxidizing nature is particularly useful in common processes, such as dissolution and amputation in the iron and steel industry.



Nitrogen(N₂)

Nitrogen is widely used in food quick-freezing and artificial insemination and serves as an important gas in semiconductor and electronics industries, it is used as a purge and carrier gas in chemical and metal heat treatment processes. Also, it interacts with metals at high temperature and pressures to form nitrides and binds with hydrogen through catalytic reactions.

Argon(Ar)

Argon is an essential gas in refinement and processing of metal that must not be exposed to oxygen, nitrogen, and impurities. It is used not only in the welding of non-metallic materials such as stainless steel and aluminum, but also in the refinement and processing of high-purity materials, including titanium, silicon, and aluminum.

4. Etching Gas

Etching gases etch the shape of a space for a circuit prior to the circuit formation inside the semiconductor. They are used to add precision when etching semiconductors with a 3D structure. SK materials provide an array of etching solutions, such as via production

and sales of Monofluoromethane (CH₃F), Hexafluorobutadiene (C₄F₆), and Difluoromethane (CH₂F₂), etc.

Monofluoromethane(CH₃F)

CH₃F, an etching gas for nitride films in 3D NAND flash memory devices, is becoming more widespread with the increase of 3D NAND use. SK materials is the first and only manufacturer of CH₃F in Korea.

Å Difluoromethane(CH₂F₂)

CH₂F₂, along with CH₃F, is a gas used in etching nitride films in NAND flash memory devices. It has been widely utilized since 3D NAND has been increasingly used in the recent.

\bigcirc_{0} Trifluoromethane(CHF₃)

Used in the process of 3D NAND Flash memory nitride layers and microscopic DRAM nitride layers etching.

္ပံလို Hexafluoroethane(C₂F₆)

 C_2F_6 is a high purity etching gas for semiconductors, used for cleaning and removal of residues inside the chamber, following metal deposition in the semiconductor manufacturing processes.



memory devices. C₄F₆ has seen a significant increase in demand.

မိုင်္ Octafluorocyclobutane(C₄F₈)

C₄F₈ is a high purity gas used in semiconductor DRAM and 3D NAND manufacturing processes, mainly used for oxide film etching.

Hydrogen Fluoride Gas (HF Gas)

parts of a circuit in the semiconductor manufacturing process.

5. Precursor

Precursors are used in the semiconductor process where various kinds of reactive gases are brought into a reactor and chemically reacted to deposit a thin film of desired material onto the wafer. SK materials produces and supplies the best quality precursors, a next-generation material, manufactured atop the essence of Japan Tri Chemical Laboratories' expertise and customer's trust gained through prompt responsiveness in the semiconductor materials market.



Used in the manufacturing of capacitors for semiconductor DRAMs and in the depositing of ZrO₂ thin films in the ALD process.



Used in the manufacturing of semiconductor DRAMs and 3D-NAND and in the depositing SiO₂ thin films in the CVD/ALD process.

CHC Ti-Precursor

CHC Hf-Precursor in HfO₂ thin-film deposition as part of the ALD process.

TiO₂ thin films in the ALD process.

C₄F₆ is used in the etching of oxide films for miniaturized DRAMs and 3D NAND flash

Hydrogen fluoride gas is used to remove residues in the chamber and to etch unnecessary

Used in the manufacturing of capacitors for semiconductor DRAMs and in the depositing

Used in the fabrication process of DRAM capacitors for semiconductor devices. Also used

6. Wet Chemical Solutions

As device structures are being advanced, wet cleaning and etch steps become more critical in the chip-making process. And It is required to develop an optimized product to customer's process and to supply huge volume with consistent quality. SK materials will be able to provide various wet chemical solutions in the near future by expanding its portfolio.

High Selectivity Phosphoric Acid (HSP)

As an etchant used to manufacture 3D NAND, HSP is used to selectively etch only nitride films out of layers of nitride and oxide films.

Ē Tungsten Etchant

An etching solution used in 3D NAND memory production that enables the selective etching of tungsten thin films and diffusion barrier films.

7. Other High-Purity Gas

We strive to provide a number of solutions to our customers through not only manufacturing but also sourcing and refining high value-added items that are in high demand thanks to the wide use of semiconductor circuit scaling and 3D NAND.

Krypton(Kr)

Kr is used as a momentum gas in the etching of deep holes in 3D NAND of semiconductors.



Silicon Tetrachloride(SiCl₄)

SiCl4 is a gas used together with Si powder when manufacturing polysilicon wafers, and is also used for deposition and etching in semiconductor manufacturing processes.

Global Partner SK materials



06. NETWORK

SK materials Xian Co., Ltd.

SK materials Shanghai Co., Ltd.

SK materials Taiwan Co., Ltd.

SK materials Japan Co., Ltd.

Sales Office / Warehouse

1077–24, Mizohigashi, Kawarada, Yokkaichi, Mie, Japan Tel. +81-59-349-5800 Fax. +81-59-349-5801

SK materials Jiangsu Co., Ltd. SK materials Shanghai Co., Ltd. SK materials Xian Co., Ltd.

A Global Partner Leading the World's **Industry Market**

The competitive edge of SK materials is well received not just in Korea but also globally. With its corporations and production plants in China, Japan, Taiwan and other cities, SK materials is now advancing into an industry-leading global partner that provides world-class products and services to customers in the high-tech semiconductor and display industries, clustered in Northeast Asia.

SK materials Co., Ltd.	Specialty gases and materials for semiconductors and displays
	Head Office and Factory: 59–33 Gaheung Gongdan–ro, Yeongju–si, Gyeongsangbuk–c Tel. 054–630–8114 Fax. 054–630–8145
	Seoul Office: Tower 1, Gran Seoul Building, 33, Jong-ro, Jongno-gu, Seoul, Korea Tel. 02-728-0910 Fax. 02-728-0998
SK airgas Incorporated	Manufacture and sale of industrial gases for IT and other industries
	255, Yongjam-ro, Nam-gu, Ulsan, Korea Tel. 070–7437–1500 Fax. 052–227–5861
SK trichem Co., Ltd.	Manufacture and sale of semiconductor precursors
	110–5, Myeonghaksandan-ro, Yeondong-myeon, Sejong-si, Korea Tel. 044–417–1570 Fax. 044–417–1571
SK showa denko Co., Ltd.	Manufacture and sale of etch gases for semiconductors
	71 Gaheunggongdan-ro, Yeongju-si, Korea Tel. 054–918–9710 Fax. 054–630–8456
Hanyu Chemical Co., Ltd.	Manufacture and sale of carbon dioxide for semiconductor processes
	72 Cheoyong-ro, Nam-gu, Ulsan, Korea Tel. 052–256–1641~6 Fax. 052–261–1682
SK materials Jiangsu Co., Ltd.	Annual production capacity(NF3) : 1,500 tons
	No.59 Longxi Road, New Area Zhenjiang, Jiangsu, China Tel. +86-511-8086-9800 Fax. +86-511-8086-9728

Sales Office / Warehouse

1211 Baoba Road, Xian Gaoxin Comprehensive Bonded Zone, Xian, Shaanxi, China Tel. +86-29-6803-9592 Fax. +86-29-6803-9591

Sales Office / Warehouse

Room 602, THE SUMMIT, 118, Suzhou Avenue West, Industrial Park Suzhou, China Tel. +86-0512-6730-2842 Fax. +86-0512-6730-2849

Sales Office / Warehouse

No.12, Nanhuan Road, Wuqi Dist., Taichung, Taiwan R.O.C Tel. +886-4-2659-5511 Fax. +886-4-2659-5517

SK trichem Co., Ltd. SK materials Co., Ltd. SK showa denko Co., Ltd. SK airgas Incorporated Hanyu Chemical Co., Ltd.

SK materials Japan Co., Ltd.

SK materials Taiwan Co., Ltd.

07. SHE MANAGEMENT

SHE Management System

SK materials is committed to building an SHE Management System for zero incidents in the workplace and the environment. Our utmost value is to operate production facility safe for our employees and peace of mind is enjoyed by all stakeholders, including our customers and local communities. We are fully dedicated to realizing these objectives.





* SAFETY CERTIFICATION STATUS OHSAS 18001 | ISO 14001

Community Emergency Response **Enhancement Activity**



- **1** Gas detection devices installed in the area surrounding the facility
- Nine locations around the facility have gas detection devices installed.
- Detection results are displayed at the entrance to the town and the facilities, while monitoring is in effect via EOC and the city government's control center.



2 Anemoscopes for the community are erected in the area surrounding the facility (Twenty anemoscope posts)





• Connected to the city government's disaster situation room.

3 Monitoring of gas leaks at facility





() Protective gear supplied according to emergency scenarios for residents within the potential radius of exposure



() The booklet on (Guidance on Responding to Chemical Accidents > shall be provided.



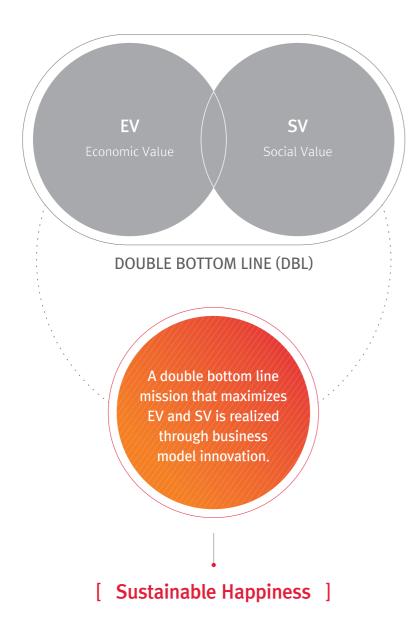
Hot line in place linking local authorities • 24-hour emergency monitoring in effect at EOC.

Emergency alarm system in place for all business operations on site

Social Value(SV)

SK materials works in harmony with the society by not only contributing to economic growth but by also generating social value so that it can build a society in which all members can achieve happiness.

Not only for corporate stability and economic growth, SK materials creates social value also for the sustainable happiness of all its stakeholders, today and in the future. This will drive the continuous growth and development of the company, thereby creating a virtuous circle. With confidence in this paradigm, SK materials dedicates resources and time towards this aim.



SK materials generates a wide range of social value so that our communities can experience **sustainable happiness**.

 Improvement of production priminize carbon emission. Investment in pollution contraction expansion of measures to reu Development of environment. promote sustainable growth.
 Expansion in investment in sa of innovative safety measure citizens, customers, partner c communities.
 Cooperation with partner cor on safety enhancement so the safety and to prevent chemica
 Building a platform for indust customers and suppliers Providing the system and infr and performance of, suppliers Increasing employment of so the physically challenged
 Exerting effort to tackle socia conditions, by active engager Creating and helping a joyfu
 Actively carrying out socially local community and revitaliz Carrying out social contribution underprivileged and nurture y



n processes to raise energy efficiency and to

ntrol devices to reduce emission of pollutants and reuse and recycle resources.

ntally friendly industrial materials for the future to h.

safety equipment and facilities, and implementation ures at the manufacturing sites will reassure all r companies, SK employees, and the regional

companies and share its knowledge and know-how that SK materials is able to contribute to national ical incidents and emergencies.

ustrial materials via open partnerships with

nfrastructure for better communication with,

ers

socially vulnerable groups via creating positions for

cial issues, such as corporate culture and working gement among the management and the employees /ful corporate culture take root

ly responsible activities to create harmony with the lize its economy

ution activities with employee so as to support the e youth talent



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